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## The 2D Semiconductor Library

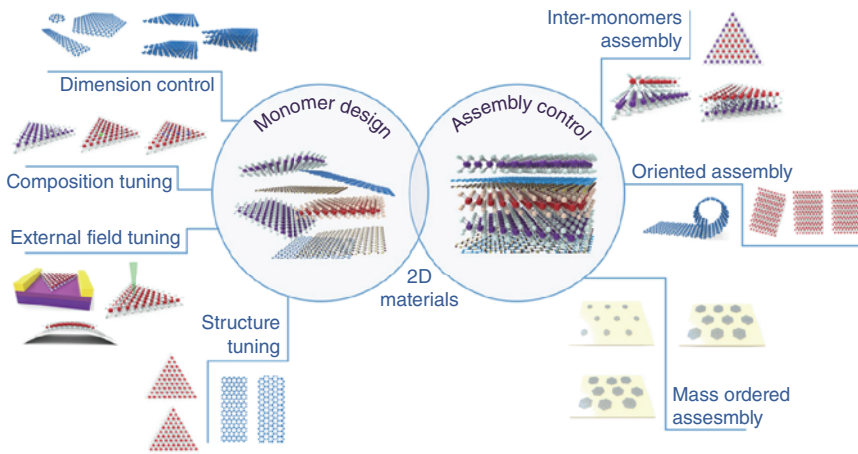
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### 1.1 Introduction

Since graphene mechanically stripped out in 2004, two-dimensional-layered materials (2DLMs) have received widespread concern due to the intrinsic changes of the physical and chemical characteristics caused by quantum confinement effect, which pertains to the nanoscale thickness [1, 2]. Since the carrier transport will be strongly restricted to the two-dimensional plane, the electronic and optoelectronic characteristics of the 2DLMs will change significantly [3, 4]. The 2D material family covers various components including most of the elements in the periodic table [5]. These 2D nanosheets usually have a well-defined crystal structure without surface dangling bonds, which has traditionally plagued most semiconductor nanostructures, and therefore exhibits superior electronic properties that are not easily available in other semiconductor nanostructures. This results in a wealth of electronic properties, as well as direct and indirect bandgaps with visible light ranges from ultraviolet to infrared [6–8]. What is more, due to the excellent adaptability of 2D geometry to the existing process techniques in the semiconductor industry, 2DLMs are able to be integrated with conventional semiconducting materials such as silicon and are able to be transferred on diverse supporting substrates. As a result, it is of great potential for them in future applications such as nanoelectronics, optoelectronics, and new ultrathin flexible devices [6–18]. Two-dimensional atomic crystal integrated circuit has been demonstrated, including memory, logic gates, amplifiers, oscillators, mixers, switches, and modulators. Two-dimensional materials of only one or a few atoms thick hold the potential to make future optoelectronics and electronic devices. The functional integrated circuits (IC) of 2DLMs helps solve the technical and fundamental problems of the electronics industry.



**Figure 1.1** Two-dimensional materials for future electronic devices: from cell unit to small integration. *Source:* Reproduced with permission from Ref. [19], © American Chemical Society 2018.

The emerging application of nanoelectronics using two-dimensional materials prerequisites a reliable preparation and controlled stacking of wafer-scale 2DLMs of high quality by taking full advantage of their unique features in the two-dimensional limit (Figure 1.1). The widespread use of 2DLMs is due to their inherent properties and, to a large extent, their adjustability. Because of the novel anisotropy and planar crystal structure of 2DLMs, their properties can be improved greatly by adjusting the composition, size, field, and structure [20]. For instance, the band structure of a two-dimensional material changes significantly as the material thickness decreases from block to single-layer limit. In addition, some two-dimensional materials can be converted from semiconductor to metal through the intercalation. The use of one material in modern technology and applications is difficult to achieve a variety of excellent performance. As a result, 2DLMs can adjust their properties to the desired functionality, opening the way for further widespread use in electronic circuits.

Furthermore, since only one or a few atoms thick, 2DLMs with different heights can be stacked to form various heterostructures without consideration of lattice matching and processing compatibility. Van der Waals (vdW) heterostructures with sharp interfaces and disparate electronic properties offer a novel platform and prosperous applications for investigation of the creation, confining, and transmission of charge, excitons, and photons at two-dimensional limit [18]. The structure of a single two-dimensional material is also worth further study because it helps to further discover the intrinsic properties of the 2DLMs. New applications can be made by extending the structural deformation derived from directional construction to the properties of 2DLMs. In addition, efficient construction techniques are disposable to the production of large-scale nanodevices with desired-ordered structures to address the scaling and integration challenges of microelectronics, photonics, and microelectromechanical systems [21–24].

## 1.2 Emerging 2DLMs for Future Electronics

The rise of graphene with excellent properties has facilitated the discovery and research of new two-dimensional materials. In addition to graphene, various two-dimensional materials are attracting focus because of their unique properties. The size effect and adjustability of its energy band structure result in some novel properties. In this section, we will look at two aspects of the emerging 2DLMs. In one part, we will give clues based on the structure of two-dimensional materials, and in the other part, we will detail the various 2DLMs that are classified by their elemental composition.

### 1.2.1 Classification

Initially, 2DLMs represented by graphene were referred to as a layered material that has strong intralayer covalent bonds and weak interlayer vdW coupling. Therefore, the layered material can be obtained by stripping the bulk material. In this case, we call them two-dimensional layered materials (2DLMs).

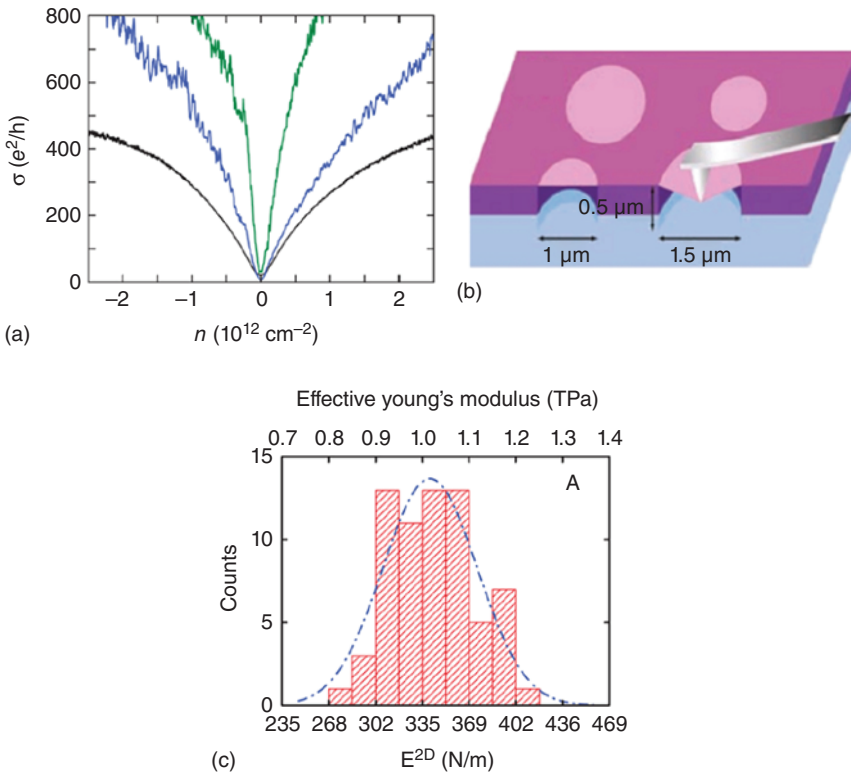
Lamellar vdW materials, which are separated into single or several layers, are one of the hot research topics. Due to the strong covalent bonds in planes and weak interlayer vdW coupling, they can be separated by mechanical or liquid stripping to form nanosheets [8, 25]. In addition to graphene, which was first discovered, transition metal dichalcogenide (TMDCs) are also typical vdW materials, such as MoS<sub>2</sub>, WS<sub>2</sub>, and WSe<sub>2</sub>. To date, more than 40 types of TMDCs have been discovered [26]. Hexagonal boron nitride (h-BN) [27], silicon carbide [28], VO<sub>2</sub> [29], and telluride antimony [30] are also included within such category.

### 1.2.2 Elemental 2DMLs

2DMLs such as III-VA group and transition group are of great interest. Because of their unique ultrathin two-dimensional limit, they exhibit superior electronic, photonic, magnetic, and catalytic properties than bulk materials. These materials are of great potential for diverse applications in field effect transistors (FET), optoelectronics, memories, and artificial synapsis [31].

#### 1.2.2.1 IV A Group

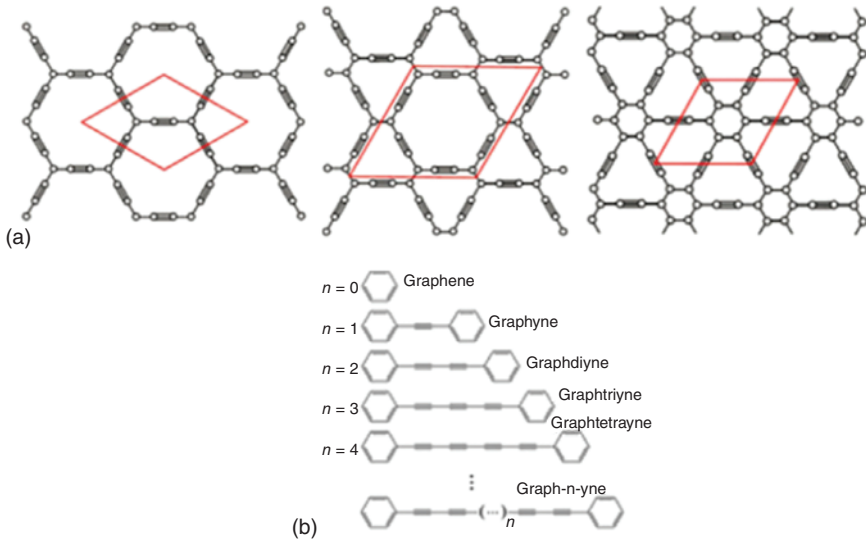
Since its discovery in 2004, graphene with the feature of honeycomb structure has been attracting great attention [2]. A range of methods for preparing graphene, such as mechanical stripping, liquid-assisted stripping, and chemical vapor deposition (CVD) methods, have rushed out. It has lots of superior properties, in particular its unprecedented high intrinsic mobility of  $200\,000\text{ cm}^2\text{ V}^{-1}\text{ s}^{-1}$  at room temperature [32]. Stampfer et al. discovered that it has the mobility at low temperature of  $350\,000\text{ cm}^2\text{ V}^{-1}\text{ s}^{-1}$ , as shown in Figure 1.2a, reaching the highest record so far [35]. The grooves are utilized to suspend graphene. The beam of laser is concentrated on graphene, after which the heat flows radially from the graphene center to the peripheral. The dependence of Raman G peak on excitation power is measured, and



**Figure 1.2** Brief introduction of graphene. (a) Relationship between conductance and density of charge carrier. The black and blue plots were obtained at 300 and 1.6 K, respectively. The green one is consistent with carrier mobility  $\mu = 350\,000 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$  from another sample. *Source:* Reproduced with permission from Ref. [33], © American Chemical Society 2008; (b) schematic of configuration about suspended graphene being indented. (c) Elastic stiffness statistics histogram of graphene. *Source:* Figure (b) and (c) reproduced with permission from Ref. [34], © Wiley Online Library 2010.

the TC of graphene is approximately  $5000 \text{ W m}^{-1} \text{ K}^{-1}$  [33]. Graphene was suspended, and Young's modulus was characterized by patterning a circular well array having a  $1.5 \mu\text{m}$  diameter and  $500 \text{ nm}$  depth on a  $\text{SiO}_2/\text{Si}$  substrate (Figure 1.2b). Figure 1.2c shows the elastic stiffness statistical histogram of suspended graphene. Young's modulus obtained by this method is about  $1.0 \text{ T Pa}$  [36]. Therefore, graphene has shown great prospect in applications of electronics, optoelectronics, energy storage, and conversion.

However, graphene still faces significant challenges because of its zero-bandgap nature, which hinders its eventual application. Another two-dimensional allotrope of carbon breaks the ice. The graphite acetylene and its derivatives composed of  $\text{sp}$ - and  $\text{sp}^2$ - hybrid carbon atoms have a certain bandgap in the band structure [37–39]. In graphene-acetylene and its derivatives, the alkyne bond is a structural unit that can be inserted to modify the graphene and retain the symmetry of the hexagon. Figure 1.3a shows the transformation of graphene to  $\alpha$ -,  $\beta$ -, and  $\gamma$ -graphene by



**Figure 1.3** Structure and optoelectronic applications of graphite-acetylene group materials. (a) Structure of alpha-, beta-, and gamma-graphene. *Source:* Figure (a) reproduced with permission from Ref. [39], © American Chemical Society 2011; (b) expansion diagram of  $n$ -alkyne based on chain length. *Source:* Reproduced with permission from Ref. [40]/ © American Chemical Society 2013.

inserting acetylene bonds between two carbon atoms in different ways [38]. The structure shown in Figure 1.3b is formed by graphite diacetylene when two acetylene bonds are inserted [39]. Acetylene chains of different lengths will generate a series of graphitic alkynes, such as graphitic alkynes, graphitic dialkynes, graphitic trialkynes, and graphitic tetrapyne. [41]

As one of the graphyne derivatives, graphdiyne can be grown by cross-coupling with hexaethynylbenzene as precursors [40, 42–45]. In general, graphdiyne can be obtained as nanowalls (NWs) [44, 45], film [42, 43], or coating layers covering  $\text{TiO}_2$  [40] by this coupling reaction. In recent years, graphdiyne was successfully prepared on the Au (111) crystal plane using molecular evaporator deposition of precursor molecules in the ultrahigh vacuum ambient of a scanning tunnelling microscopy (STM) [46]. Nishihara et al. successfully prepared multiple layers and few layers of graphite-diacetylene through liquid/liquid or gas/liquid interface reactions [47]. Its properties are predicted successfully by theoretical calculation. Graphyne allotropes feature an intrinsic bandgap ( $\sim 1.2\text{eV}$  for graphyne and  $\sim 0.46\text{eV}$  for graphdiyne), and their direct bandgaps indicate their potential applications in optoelectronic devices [48, 49]. Two-dimensional graphene with Dirac dots and cones still exist, such as  $\alpha$ -graphene with a single Dirac cone and 6,6, 12-graphene with two different Dirac cones [49, 50]. The different atomic structure of graphyne alkyne results in the difference of electronic structure [51]. Graphyne group material as a new 2DLM has excellent application prospects in electronic devices and photovoltaic devices [40, 43, 49]. Li et al. constructed a solar cell with

high efficiency electron transport based on graphite-diacetylene doped benzene-C61-methyl butyrate, as shown in Figure 1.3 [52]. Although graphyne family materials have excellent carrier mobility with a proper bandgap, the challenge of synthesizing single crystal with large scale and high quality has severely limited the further application development of graphite-based alkyne. Wherefore, new methods are urgently needed to achieve the preparation of such high-quality materials.

In addition to carbon, other elements of the IVA group can also form 2DLMs, including silene, germanene, and tinene. The atoms in silicene or germanene are connected with each other through  $sp^3$  hybridization, which is more stable than the  $sp^2$  hybridization. Even if they are not able to exist as independent lamellae, they can still be successfully obtained as layered materials. At present, lots of methods have been reported to grow silene. One of the most effective methods of wet chemistry is the stripping of 2DLMs by an exchangeable Ca layer and an interlinked Si6 ring consisting of  $CaSi_2$  [53]. Some used HCl solution and Mg to further reduce layer-to-layer interactions [54, 55]. In addition, the most common approach is the vapor deposition on selected substrates, such as Ag (111) [56], Ag (110) [57], Au (110) [58], Ir (111) [59],  $MoS_2$  [60],  $ZrB_2$  [61], and H- $MoSi_2$  [62] in STM. Excellent physical features of silicene, including the quantum spin Hall effect [63, 64], ferromagnetism [65, 66], germanium doping controlled TC [67], and semi-metallic properties [68] have been predicted by theoretical calculations [69].

Germanene can be prepared in a comparable method as silicene, including  $CaGe_2$ -assisted chemical exfoliation [70] and vapor deposition [71–73]. Germanene features a number of exclusive characteristics, including robust structure [74], semi-metallic property [75], high exciton resonance [76, 77], high carrier mobility [78], Dirac characteristics [79, 80], photon properties of ground state [81, 82], negative thermal expansion [83], spin electron transport [84], tunable magnetism [85], many body effects [86], infrared absorption [87, 88], and great thermoelectric properties [89]. The charge carriers of germanium materials, whose electronic structure is similar to graphene and silicon, are massless fermions. Using a vertical electric field can open the bandgap in a single layer of flexed silicon and germanene [90]. In addition, novel properties of the quantum spin hall effect are able to be realized by halogen or hydrogen elements modification [91, 92].

The Sn (111) diatomic layer where two triangular sublattices are stacked to generate a crooked honeycomb lattice that forms the stanene. Based on the substrate  $Bi_2Te_3$  (111), stanene can be prepared by molecular beam epitaxy (MBE) [93]. Excellent properties have been predicted through theoretical calculations [94], such as stress-affected mechanical properties, novel thermal transport diffusion properties [95, 96], unique electronic features [97], phase transition between topological phase to insulating one [98], large magneto-resistive [99], super conductivity [100], and quantum spin Hall effect [101].

#### 1.2.2.2 V group A

Two-dimensional materials composed of V-A group elements include black phosphorus (BP), arsenic, antimony, and bismuth. In 1914, BP was successfully prepared [102, 103], where each atom was covalently connected to three adjacent atoms

to create a folded monolayer honeycomb. [104] From bulk to monolayer, the bandgap of BP increases (0.3 up to 1.5 eV). In addition, it has been proved that the room temperature carrier mobility of BP in several layers of quasi-2D phosphors is up to  $1000 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$  [105]. Therefore, BP shows significant prospect in applications of electronic and photonic devices [106]. Current methods for producing BP include mechanical stripping [107–109], liquid stripping, [110–113] and CVD [114]. At the same time, the thickness of BP determines its properties, for example photoluminescence (PL) spectroscopy [109, 110]. BP has been demonstrated to show great potential applications in photoelectric fields [107], including photodetectors and solar cells. [115] BP is studied through simulation experiment and theory analysis of many properties, including stacking-sequence-dependent electronic structure [116–118], anisotropic properties [114], transmission characteristics between magneto-optical [119], controlled band structure [120, 121], flexibility [122], thermal properties [123], anisotropic exciton [124], and electrical conductance [125]. Interestingly, blue phase [126, 127] and topological insulator conversion of BP are proved [128].

Structurally, a layer of arsenic atoms with a rhombic structure forms arsenic. Thickness of 14 nm arsenic was successfully grown on InAs substrate via plasma-assisted process [129]. It has been theoretically calculated that arsenic has many exclusive characteristics, covering anisotropic-controlled TC [130] and strain-modulated topological insulator conversion [131].

The most stable V-A group allotropes is antimonene with monolayer antimony. The bandgap is predicted as 2.28 eV. At present, the approaches of preparing antimonene are mainly mechanical stripping [132], liquid exfoliation [133], MBE [134], and CVD [135]. Antimonene is predicted theoretically to feature some novel characteristics, including spin-orbit coupling (SOC) effect [136], geometry-controlled TC [137], defects-controlled electronic properties [138], and UV detection [139]. Indirect to direct bandgap transition would occur through a small stress, further advancing its potential in optoelectronic applications [140, 141].

In 2005, bismuth was first grown on atomically smooth surfaces [142]. After that, bismuth was successfully obtained by wet chemical synthesis [143]. Theoretical calculations show that bismuthene has a lot of nice attributes. At high temperature, bismuth is insensitive to long wavelength vibration and thermal excitation. As the 3D bulk is scaled into individual single-layer sheets, the bismuthene's structure is compressed, resulting in a transformation from a semi-metal to a semiconductor. Nevertheless, such thickness dependence does not affect the topological characteristics of bismuthene [144, 145].

### 1.2.2.3 III A Group

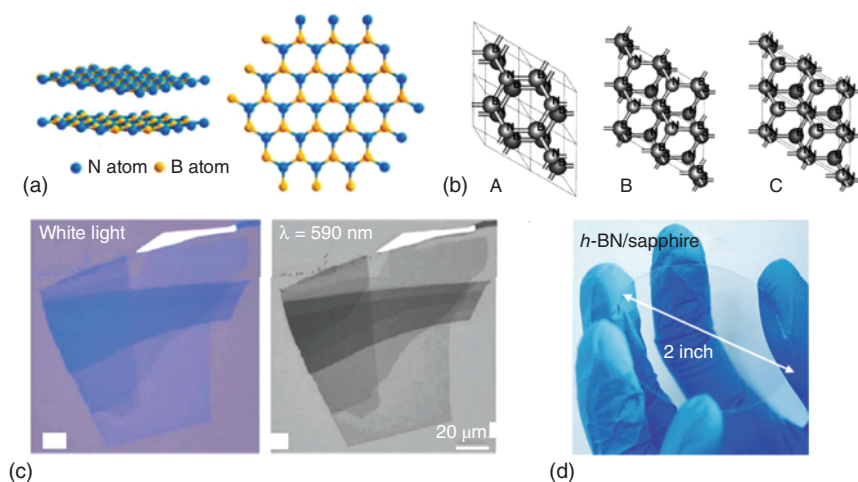
In Group III A, the last specific elemental 2DM is borophene. Boustani first proposed the quasi-planar boron structures through theoretical calculations [146]. Later, methods for preparing borophene, such as vapor deposition [147, 148] and two-growth-zone CVD, were reported [149]. More simulations show that borophene has lots of special attributes, such as high work function [150], magnetism [151], and extremely high hydrogen storage capacity [152]. In addition, two-dimensional

borophene has potential applications of power generation, electrical transmission, energy storage, and electrocatalysis [153, 154].

### 1.2.3 Hexagonal Boron Nitride (h-BN)

After the discovery of graphene, atomically thin h-BN has also attracted continuous attention in the field due to excellent performance and potential application prospects. The single-layer h-BN has a crystal structure similar to graphene, so it is often referred to as “white graphene.” It consists of alternating covalent B and N atoms in a hexagonal basal plane (space group =  $P6_3/mmc$ ) and is free of dangling bonds between the layers (Figure 1.4a,b). These layers stack together to form the bulk crystal by the vdW force [159]. The bulk h-BN shows lattice constants ( $a = 2.504 \text{ \AA}$ ) and interlayer distances ( $3.30\text{--}3.33 \text{ \AA}$ ) [155].

Having different physical properties from graphene, h-BN is a typical insulator with high relative permittivity and an indirect bandgap of about 6 eV. In addition, h-BN has many other properties including chemical stability, thermal stability, high TC, great mechanical flexibility, atomically flat surface, free of dangling bonds, and charged impurities [156]. This makes h-BN in the field of microelectronics, especially in the vdW electronic field, a broad application prospect. First, h-BN is an appealing substrate dielectric for 2D material-based devices [160]. Compared with traditional substrate dielectric, graphene and other two-dimensional materials using h-BN as dielectric substrate can improve the carrier mobility and realize rapid



**Figure 1.4** (a) Crystal structures of h-BN. *Source:* Reproduced with permission from Ref. [155], © Chemical Reviews 2017; (b) three structures of h-BN all have space group  $P6_3/mmc$  and can be transformed into one another by translational gliding moves of the BN plane. *Source:* Reproduced with permission from Ref. [155], © Physical Review B 2003; (c) exfoliated h-BN nanosheets from h-BN single crystals on the 90 nm  $\text{SiO}_2$  substrate. *Source:* Reproduced with permission from Ref. [156], © Nano Micro small 2011; (d) photograph of a wafer-scale SC-hBN film on a  $\text{SiO}_2$ -Si wafer. *Source:* Reproduced with permission from Ref. [157, 158], © Advanced Materials Interfaces 2018.